

Notice of References Cited	Application/Control No. 10/531,897		Applicant(s)/Patent Under Reexamination KIM ET AL.	
	Examiner CONNIE P. JOHNSON		Art Unit 1795	Page 1 of 1

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*	B	US-6,411,591	06-2002	Moritani et al.	369/275.2
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*	D	US-5,368,986	11-1994	Terao et al.	430/270.12
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NON-PATENT DOCUMENTS

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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